

# Optical properties of strain-compensated hybrid InGaN/InGaN/ZnO quantum well light- emitting diodes

S.-H. Park<sup>1</sup>, S.-W. Ryu<sup>1</sup>, J.-J. Kim<sup>1</sup>, W.-P. Hong<sup>1</sup>, H.-M  
Kim<sup>1</sup>, J. Park<sup>2</sup>, and Y.-T. Lee<sup>3</sup>

<sup>1</sup> Department of Electronics Engineering, Catholic University of Daegu, Hayang,  
Kyongsan, Kyongbuk, Korea 712-702

<sup>2</sup> Energy and Applied Optics Team, Gwangju Research Center, Korea Institute of  
Industrial Technology, Gwangju 500-480, Korea

<sup>3</sup> Department of Information and Communications, Gwangju Institute of Science  
and Technology, 1 Oryong-dong, Buk-gu, Gwangju, 500-712, Republic of Korea

# Overview

- Introduction
- Theoretical background
- Results and Discussion
- Summary

# Introduction

- **Wurtzite GaN-based QW Structures**

Potential and existing optoelectronic device applications : laser diode, traffic lights, displays, and so forth

- **Properties of (0001)-oriented WZ GaN-based QW structures: Several disadvantages, compared to conventional ZB GaAs- or InP-based QW structures**

- **Large internal field due to PZ and SP polarizations**

→ Lower internal efficiency

- **Green InGaN/GaN QW LEDs show much less efficiency than that of blue InGaN/GaN QW LEDs**

← higher In composition and thick well width are needed to obtain longer wavelength



# Hybrid InGaN/ZnO structures

- Reduce the internal field to obtain high performance short-wavelength LEDs
- By now, several methods such as using non-polar plane, inserting delta layer into InGaN well region, using ultra thin well width, and using quaternary InGaAlN barrier have been proposed to reduce the effect of the internal field due to polarizations.
- Among them, ZnO and related oxides :  
← new wide band-gap semiconductors
- In particular, an alternative approach based on hybrid LED heterostructures combining p-doped GaN and n-doped ZnO epitaxial materials has been demonstrated by several

# Hybrid InGaN/ZnO structures

- **With the current progress in the hybrid LED structures, the internal field engineering in the hybrid InGaN/InGaN/ZnO QW structures grown on ZnO substrate become very important for the realization of high efficiency green LEDs.**
- **Strain-compensated structure is possible.**

Electronic and optical properties of 530 nm hybrid InGaN/InGaN/ZnO QW structures

→ Compare with those of conventional InGaN/GaN QW structures



# ZnO substrate : Strain-compensated structure

$a(\text{InN})=3.53 \text{ \AA}$   
 $a(\text{GaN})=3.1892 \text{ \AA}$

$a(\text{ZnO})=3.2505 \text{ \AA}$



ZnO  
substrate

(a) Tensile  
 $\text{In} < 0.18$



ZnO  
substrate

(b) Compressvie  
 $\text{In} > 0.18$



GaN  
sub.

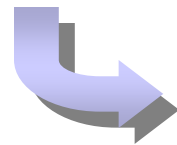
(c) Always  
compressive

# Valence band structure: (0001)-oriented Hamiltonian

$$H(\mathbf{k}, \epsilon) = \begin{pmatrix} F & -K^* & -H^* & 0 & 0 & 0 \\ -K & G & H & 0 & 0 & \Delta \\ -H & H^* & \lambda & 0 & \Delta & 0 \\ 0 & 0 & 0 & F & -K & H \\ 0 & 0 & \Delta & -K^* & G & -H^* \\ 0 & \Delta & 0 & H^* & -H & \lambda \end{pmatrix} \begin{matrix} |U_1\rangle \\ |U_2\rangle \\ |U_3\rangle \\ |U_4\rangle \\ |U_5\rangle \\ |U_6\rangle \end{matrix}$$

**Bases**

$$\begin{aligned} |U_1\rangle &= -\frac{1}{\sqrt{2}}|(X + iY) \uparrow\rangle, \\ |U_2\rangle &= \frac{1}{\sqrt{2}}|(X - iY) \uparrow\rangle, \\ |U_3\rangle &= |Z \uparrow\rangle, \\ |U_4\rangle &= \frac{1}{\sqrt{2}}|(X - iY) \downarrow\rangle, \\ |U_5\rangle &= -\frac{1}{\sqrt{2}}|(X + iY) \downarrow\rangle, \\ |U_6\rangle &= |Z \downarrow\rangle. \end{aligned}$$



$$\begin{aligned} F &= \Delta_1 + \Delta_2 + \lambda + \theta, \\ G &= \Delta_1 - \Delta_2 + \lambda + \theta, \\ \lambda &= \frac{\hbar^2}{2m_o} [A_1 k_z^2 + A_2 (k_x^2 + k_y^2)] + \lambda_\epsilon, \\ \theta &= \frac{\hbar^2}{2m_o} [A_3 k_z^2 + A_4 (k_x^2 + k_y^2)] + \theta_\epsilon, \\ K &= \frac{\hbar^2}{2m_o} A_5 (k_x + ik_y)^2 + D_5 \epsilon_+, \\ H &= \frac{\hbar^2}{2m_o} A_6 (k_x + ik_y) k_z + D_6 \epsilon_{z+}, \\ \lambda_\epsilon &= D_1 (\epsilon_{zz}) + D_2 (\epsilon_{xx} + \epsilon_{yy}), \\ \theta_\epsilon &= D_3 (\epsilon_{zz}) + D_4 (\epsilon_{xx} + \epsilon_{yy}), \\ \epsilon_+ &= \epsilon_{xx} - \epsilon_{yy} + 2i\epsilon_{xy}, \\ \epsilon_{z+} &= \epsilon_{xz} + i\epsilon_{yz}, \\ \Delta &= \sqrt{2}\Delta_3. \end{aligned}$$

# Self-consistent solution with screening effect

The self-consistent (SC) band structures and wave functions are obtained by solving the Schrodinger equation for electrons, the 6x6 Hamiltonian for holes, and Poisson's equation iteratively.

Total potential profile for electron and hole

$$\begin{aligned} V_c(z) &= V_{cw}(z) - |e|\phi(z), \\ V_v(z) &= V_{vw}(z) - |e|\phi(z), \end{aligned}$$

where  $V_w$ =square-well potential

Electron and hole concentrations

$$n(z) = \frac{kTm_e}{\pi\hbar^2} \sum_n |f_n(z)|^2 \ln \left( 1 + e^{[E_{fc} - E_{cn}(0)]/kT} \right)$$

$$p(z) = \sum_{\sigma=U,L} \sum_m \int dk_{\parallel} \frac{k_{\parallel}}{2\pi} \sum_{\nu} |g_{mk_{\parallel}}^{\sigma(\nu)}(z)|^2 \left( \frac{1}{1 + e^{[E_{fv} - E_{vm}(k_{\parallel})]/kT}} \right),$$

Poisson equation

$$\frac{d}{dz} \left( \epsilon(z) \frac{d}{dz} \right) \phi(z) = -|e|[p(z) - n(z)],$$

Potential

$$\phi(z) = - \int_{-L/2}^z E(z') dz',$$

where

$$E(z) = \int_{-L/2}^z \frac{1}{\epsilon(z)} \rho(z') dz'.$$



# Non-Markovian model with many-body effects for spontaneous emission spectrum

$$g_{sp}(\omega) = \sqrt{\frac{\mu_0}{\epsilon}} \sum_{\sigma=U,L} \sum_{l,m} \left( \frac{e^2}{m_o^2 \omega} \right) \int_0^\infty dk_{||} \frac{k_{||}}{\pi L_w^{eff}} |\hat{\epsilon} \cdot \mathbf{M}_{lm}^\sigma(k_{||})|^2 f_l^c(k_{||}) [1 - f_m^v(k_{||})] L(\omega, k_{||})$$

$$L(\omega, k_{||}) = \frac{(1 - \text{Re}Q(k_{||}, \hbar\omega)) \text{Re}L(E_{lm}(k_{||}, \hbar\omega)) - \text{Im}Q(k_{||}, \hbar\omega) \text{Im}L(E_{lm}(k_{||}, \hbar\omega))}{(1 - \text{Re}Q(k_{||}, \hbar\omega))^2 + (\text{Im}Q(k_{||}, \hbar\omega))^2}$$

$$\text{Re}[L(E_{lm}(k_{||}, \hbar\omega))] = \sqrt{\frac{\pi \tau_{in}(k_{||}, \hbar\omega) \tau_c}{2 \hbar^2}} \exp\left(-\frac{\tau_{in}(k_{||}, \hbar\omega) \tau_c}{2 \hbar^2} E_{lm}^2(k_{||}, \hbar\omega)\right)$$

$$\text{Im}[L(E_{lm}(k_{||}, \hbar\omega))] = \frac{\tau_c}{\hbar} \int_0^\infty \exp\left(-\frac{\tau_c}{2 \tau_{in}(k_{||}, \hbar\omega)} t^2\right) \sin\left(\frac{\tau_c E_{lm}(k_{||}, \hbar\omega)}{\hbar} t\right) dt.$$

$|\mathbf{M}|^2$  : Momentum matrix element

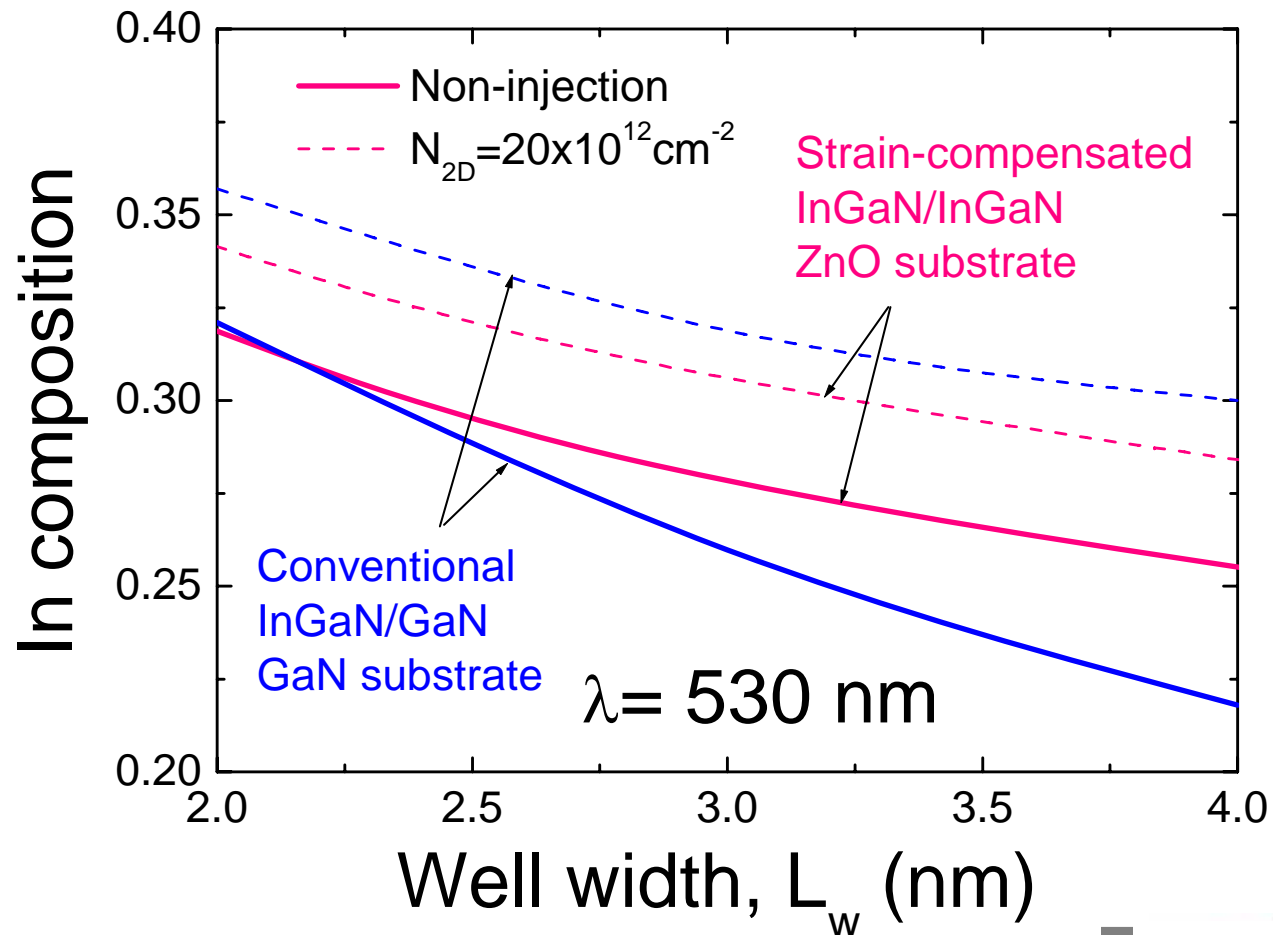
$f_n$  and  $f_m$  : Fermi functions

L : Gaussian line shape function renormalized with many-body effects

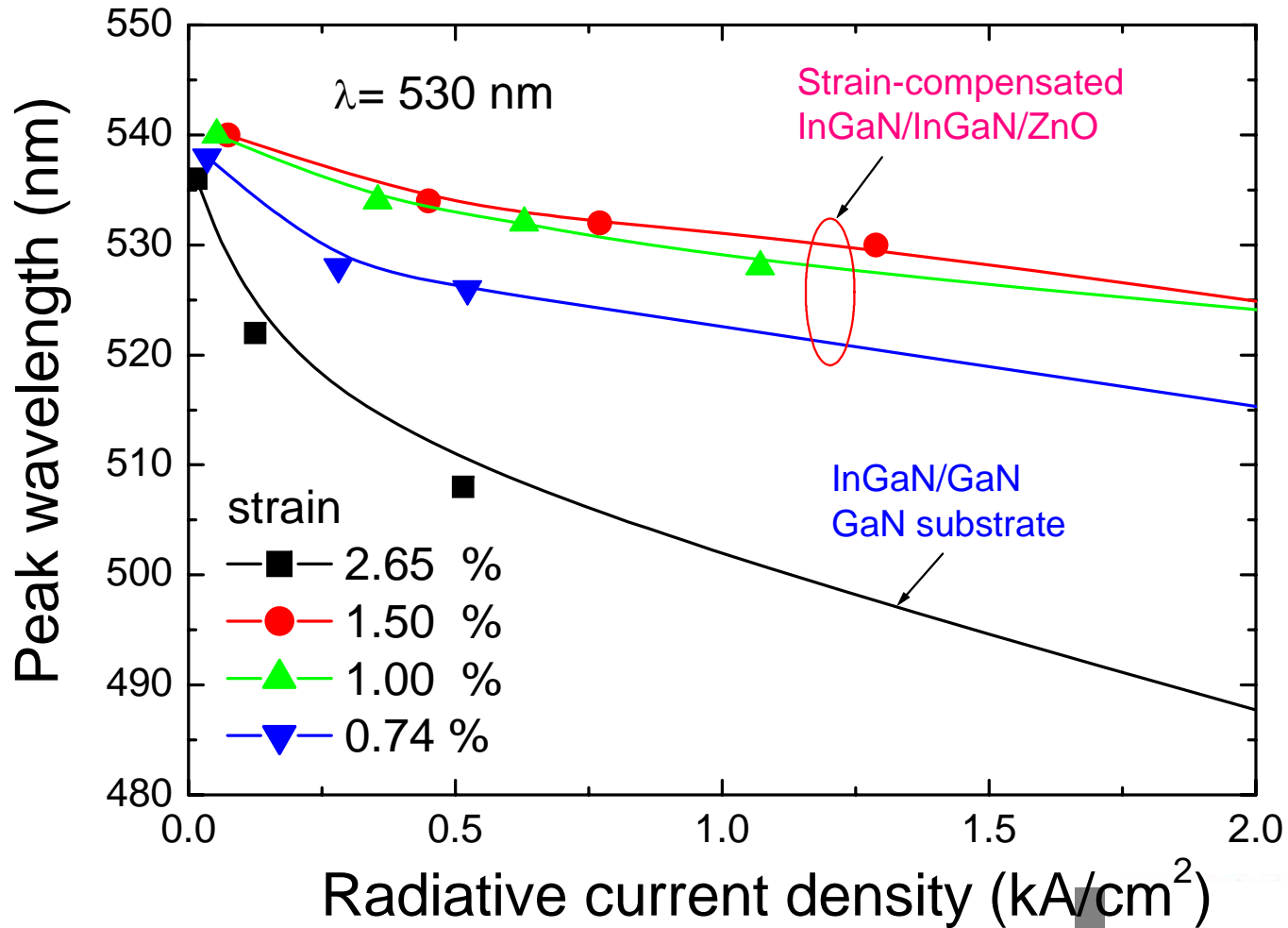
Q : CE many-body effect



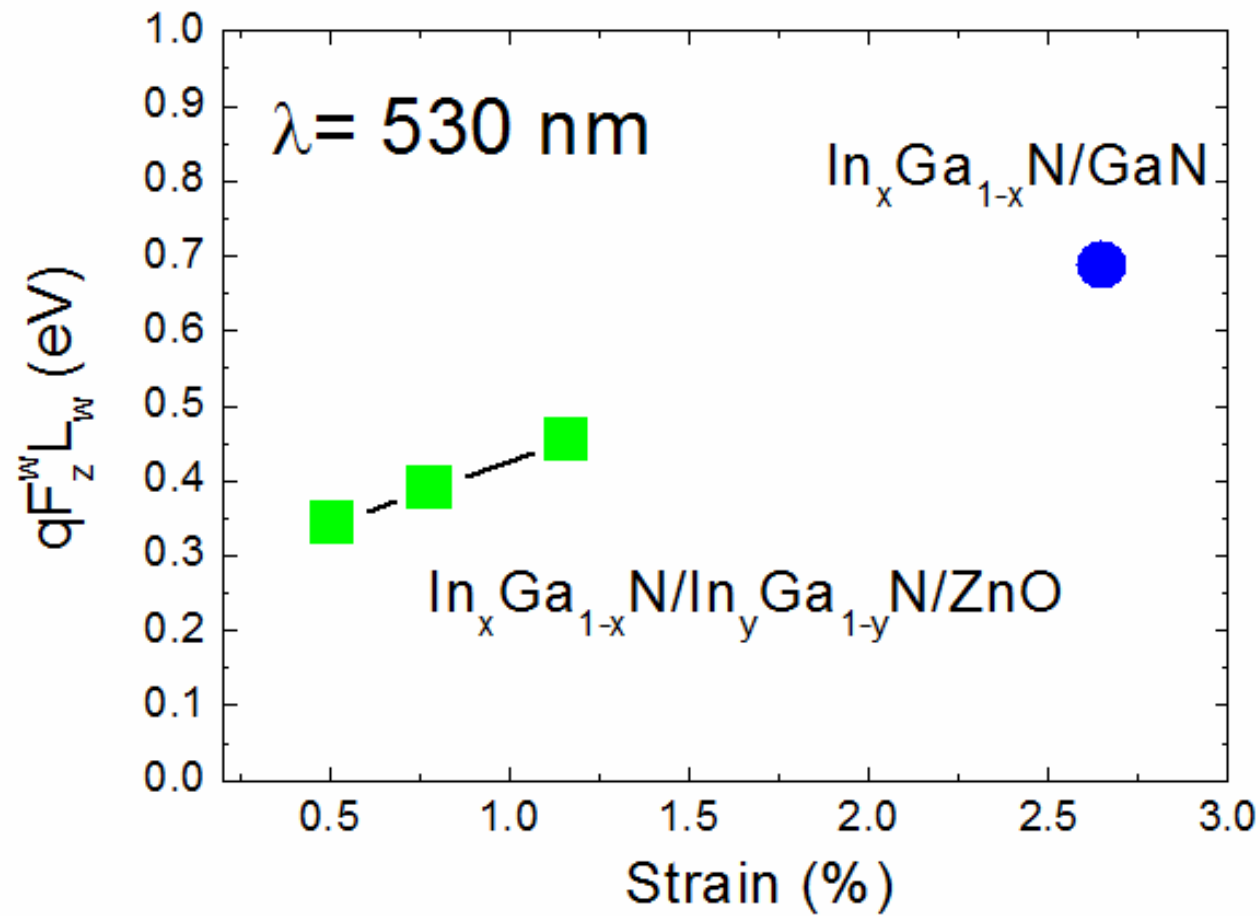
# In composition as a function of well width to obtain transition wavelength of 530 nm



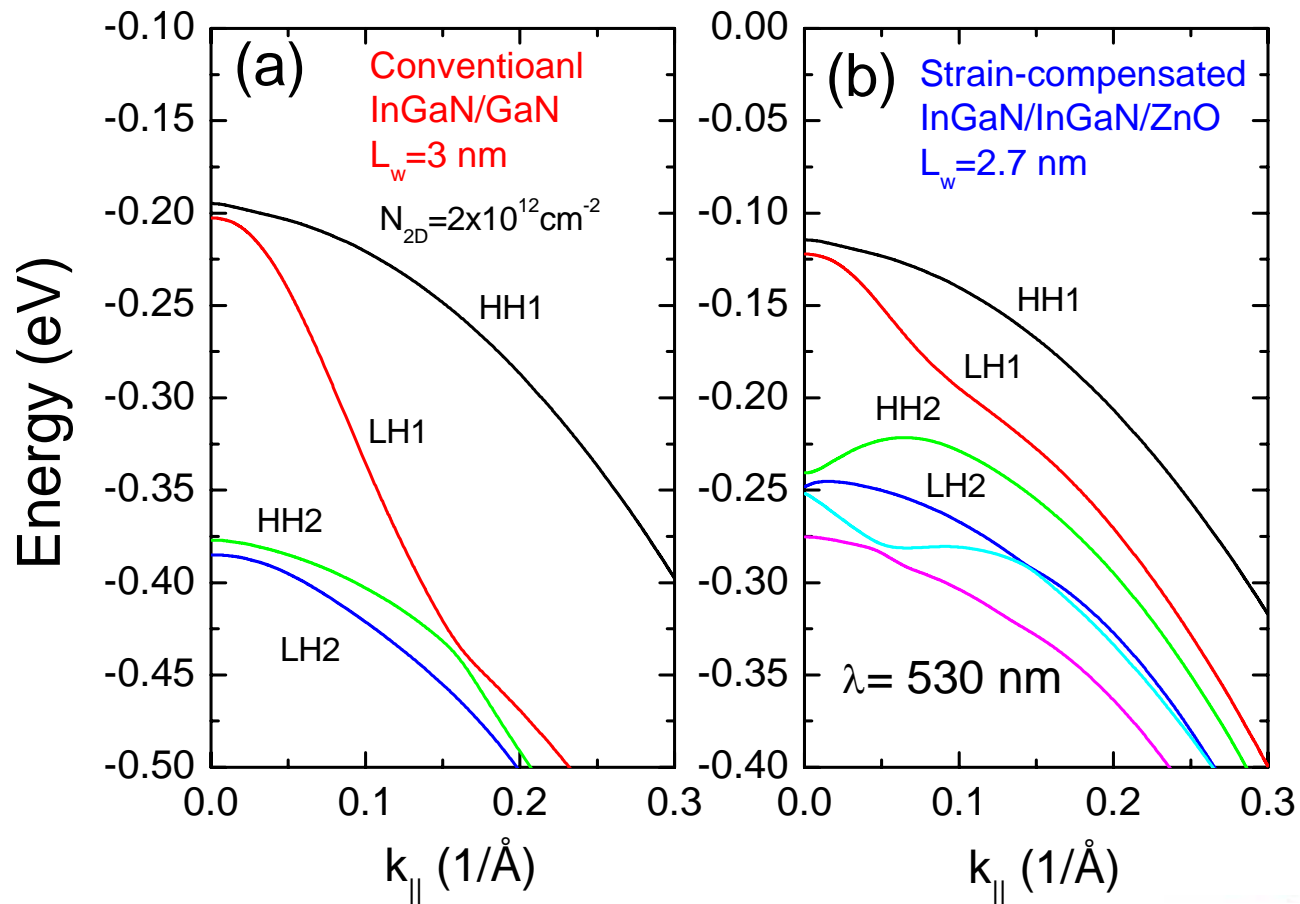
# Peak wavelength as a function of radiative current density



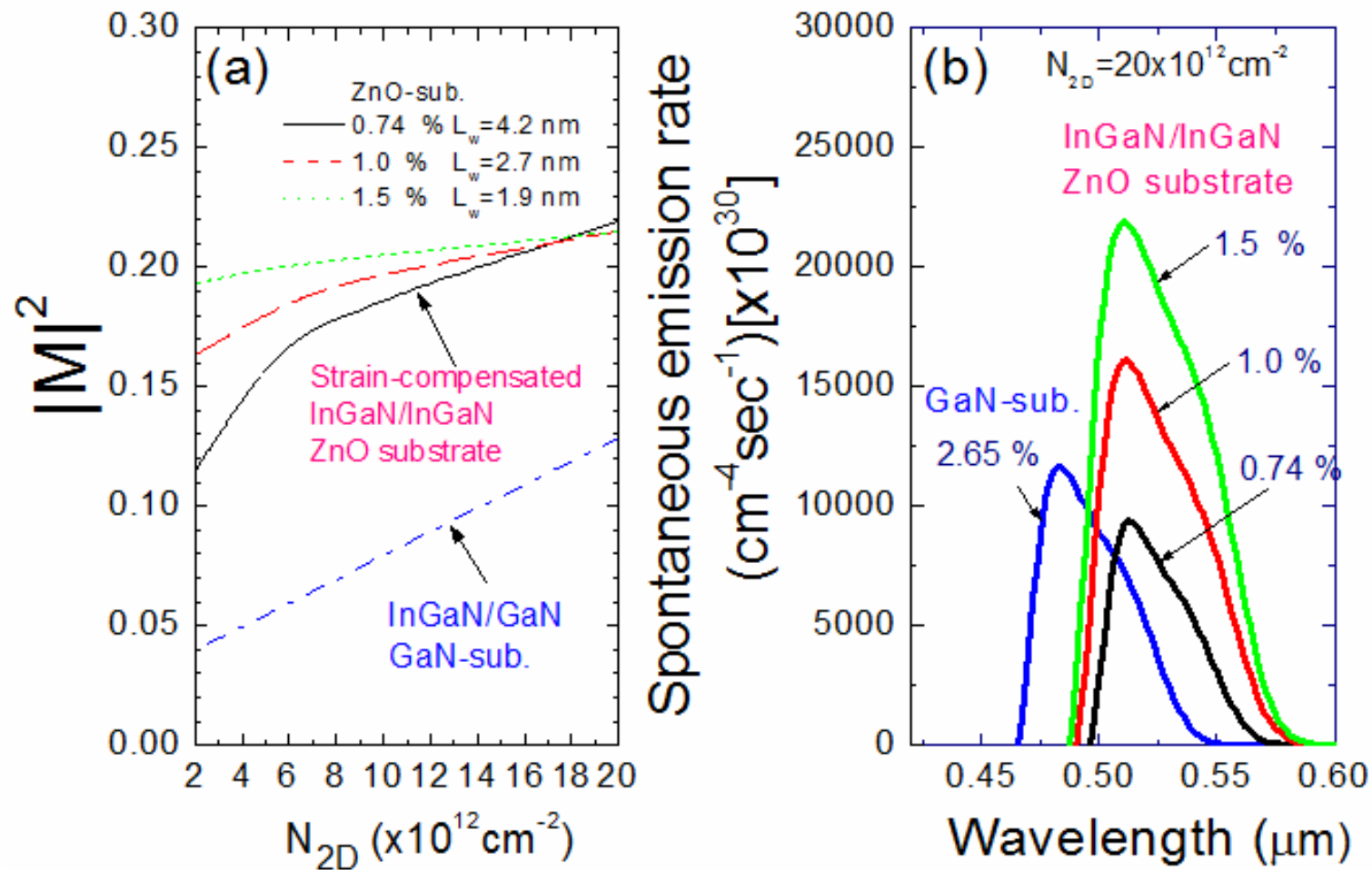
# Potential energy induced by internal field



# Valence band structure



# Optical matrix elements and Spontaneous emission rate



# Summary

- ❖ A strain-compensated QW structure with a relatively larger strain (1.5 %) is found to have **much larger spontaneous emission** than a InGaN/GaN QW structure, due to the **reduced internal field effect**.
- ❖ Also, in the case of a strain-compensated QW structure, the current density **dependence of the peak wavelength** is shown to be **largely reduced**, compared to the InGaN/GaN QW structure.

